Soft x-ray spectroscopy, microscopy, and spectromicroscopy

IFP's soft x-ray analytics facility WERA at ANKA provides a coherent combination of electron spectroscopies and microscopies for studying in detail the chemical (electronic) and magnetic structure of bulk materials, thin films, and micro- and nanostructured objects.

Special features

- The excitation (photon) energies are in the *soft x-ray range* from 100–1500 eV, which is especially well suited for studying the light elements (like oxygen), the 3d transition metals, and the 4f rare-earth elements at their particularly informative K, L, and M edges, respectively. In the soft x-ray range, radiation-induced damage in, e.g., carbonaceous materials is orders of magnitude less than with electron bombardment (like for EELS in TEM). The photon energy resolution Δ E/E can be chosen as low as 10⁻⁴.
- The main instrument for KNMF applications is the *photoemission electron microscope (PEEM)*. Using electron optics with great magnification, the lateral distribution of electrons emitted from the illuminated spot on the sample is imaged to an intensifier and CCD camera. The lateral resolution in PEEM can be better than 30 nm (100 nm in spectromicroscopy), and this as well as the variable probing depth of <1 to about 10 nm, depending on technique, is well matched to many nano- and microstructured materials and their typical length scales. Generally, the methods are element-specific. Two main modes are used:</p>

(1) *Imaging* of chemical (electronic), magnetic, and topographic contrast. The field of view can be chosen from 250 μ m down to about 20 μ m. Using the sample translation stage, a total sample area of up to about 10 mm diameter can be studied.

(2) Spectromicroscopy. This is an especially powerful PEEM application: by taking stacks of images while tuning the photon energy or the kinetic energy of the detected electrons, laterally resolved sets of x-ray absorption (μ -XAS) and photoemission (μ -PES, μ -XAS) spectra, resp., are efficiently obtained and can be further analyzed, see Fig. 2. Field of view and accessible sample area are the same as in (1). The polarization of the synchrotron radiation is a further useful variable: with circular polarization, for instance, ferromagnetic domains become visible ("magnetic dichroism", μ -SXMCD), see Fig. 3, and the associated spectromicroscopy gives element-specific magnetic information such as on spin and orbital magnetic moments. Linear polarization of the incident light makes the experiment sensitive to parameters like molecular and bond orientation.

In addition, WERA comprises further, complementary stations for XAS, PES (XPS), and SXMCD. There, the signal is averaged over the illuminated spot on the sample (typically 1x0.5 mm²). This allows higher energy resolution and even greater flexibility in detection methods, polarization, and sampling depth (including fluorescence detection for bulk-sensitive XAS measurements). The sample environment includes temperatures between 15 and 800 K and high magnetic field (currently 2 T).

INFORMATION

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Technology

Electron spectroscopy and spectromicroscopy: XAS, PES (XPS), SXMCD, μ-XAS, μ-PES (μ-XAS), μ-SXMCD, topography

Equipment

Three experimental stations at WERA equipped with PEEM, electron energy analyzer, detectors, cryostats, etc. Sample preparation chambers, loadlocks, in-vacuo sample transfer.

Material class

Silicon	Polymer	Metal	Ceramic
X	X	X	(X)
Glass	Organic	Biological sample	
(X)	X	X	



Fig. 1: Part of the cluster of experimental stations, preparation chambers, and loadlocks at WERA. The PEEM is located near the center.

- A number of sample preparation chambers and loadlocks are part of WERA. All are interconnected with the experimental chambers by an in-vacuo sample transfer system enabling the combined investigation with methods in different chambers without the need to break the vacuum. The available preparation and characterization methods include pulsed-laser deposition, evaporation (Knudsen cell), sputtering, annealing in vacuum or gases including oxygen, LEED, and RHEED. Compatibility with ANKA's NanoLab and the future KNMF laboratory at ANKA will ensure an even wider range of possibilities for preparation and characterization.
- All methods at WERA are embedded in both the KNMF and the ANKA user landscape. The WERA personnel has a strong commitment to user support. Please discuss your application with us.
- WERA is constantly being upgraded and expanded. Major upgrades in 2010 include: (i) an undulator as a second, alternative light source for experiments needing higher photon flux density on the sample; (ii) expanding the magnetic fields available for SXMCD to 7 T; and (iii) adding an experimental station for soft x-ray scattering.

Limitations/constrains

 All experiments are performed in ultrahigh vacuum at pressures in the 10⁻¹⁰ mbar range. Samples should be compatible with this.

Typical samples



Fig. 2: Nanolithography of phospholipids by the dip-pen method (see KNMF Laboratory for Micro- and Nanostructering, p. 12 in this booklet). The written triangles are 10 µm wide. The increasing admixture of nickel-chelating lipids (with a single Ni atom per lipid macromolecule) to the carrier appears in this Ni-sensitive, spectromicroscopic image as the increasingly red-yellow colors visible from bottom to top. Quantitative analysis reveals that for the lower four triangles, the admixture ratios observed in the written patterns directly track the original values. For the top triangle, some demixing seems to set in, leading to a smallerthan-expected fraction of Nichelating lipids actually arriving in the written pattern. (Cf. S. Sekula et al., Small (2008)).



Fig. 3: Magnetic domains and possibly defectrelated subdomains with various orientation are visible in this magnetic dichroism image of thinfilm permalloy squares.